





SILICON Sputtering Target

Silicon has many applications in various industries; for example, ultra high purity silicon is used in the semiconductor industry as a result of its semiconducting properties. Silicon have a broad range of applications. Just to name a few: microelectronics, durability coatings, optical filters, sensor, fiber optics, photovoltaic, anti-reflection, band pass filters, acoustical attenuation etc.

Quick Facts

Product Silicon Sputtering Target

Stock No NS6130-10-1134

CAS 7440-21-3

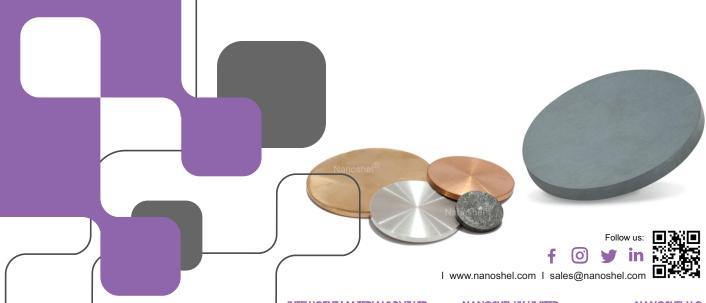
Backing Plate (As per Customer requirement)

Additional Characteristics

Stock No.	Purity	Diameter	Thickness
NS6130-10-1134	99.99%	50.8 mm ± 1mm	3 mm ± 0.5mm

Technical Specification

Molecular Formula	Molecular Weight	Melting Point
Si	28.085g/mol	1410 °C







ISO 9001:2015 CERTIFIED COMPANY **INTELLIGENT MATERIALS PVT LTD**

Punjab (140507) INDIA

+91 9779 550077, 9779238252

NANOSHEL UK LIMITED

Chapel House, Chapel St Cheshire, CW12 4AB United Kingdom

NANOSHEL LLC 3422 Old Capitol Suit 1305 Wilmington DE - 19808 United States

+44 (0) 74 105 488, +44 203 137 5187

+1 646 470 4911